

Supporting Information

Influence of Fluorine Substituents on the Film Dielectric Constant and Open-circuit Voltage in Organic Photovoltaics

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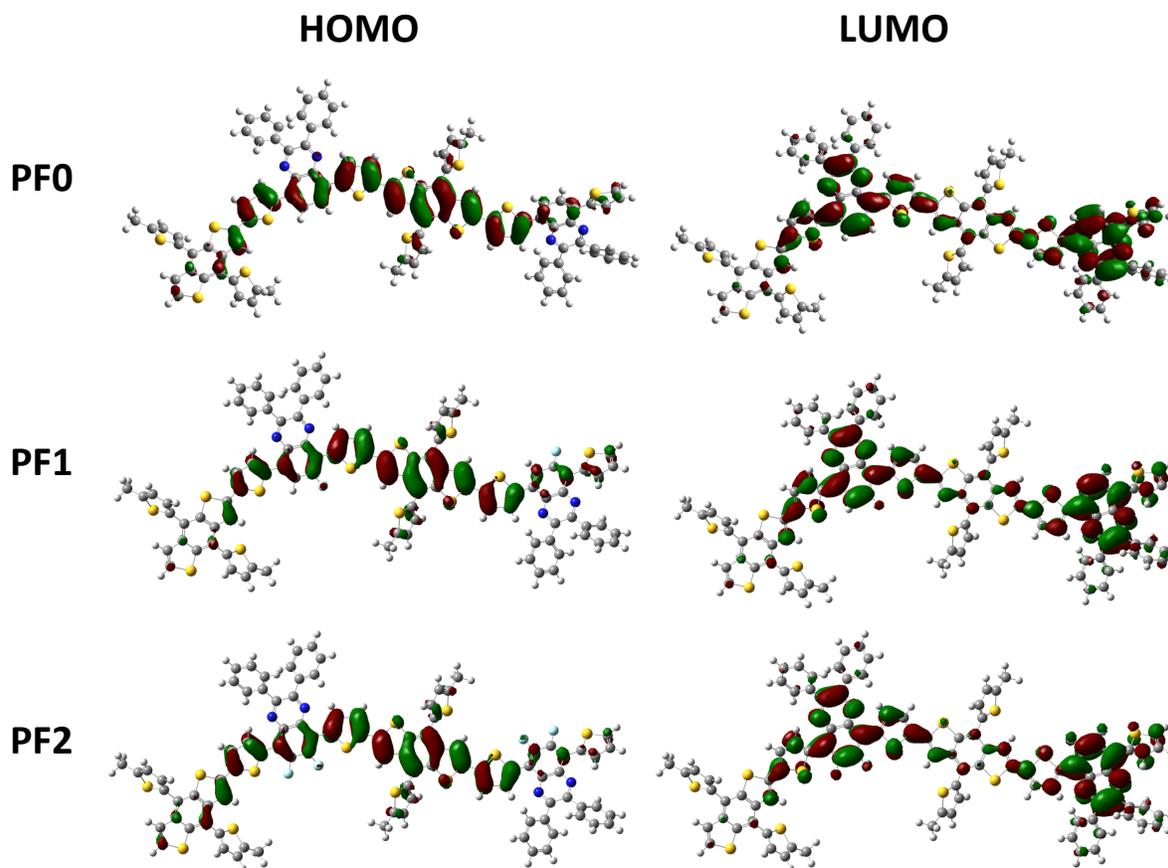


Figure S1 Optimized structures and calculated frontier orbitals for P0F, P1F and P2F.

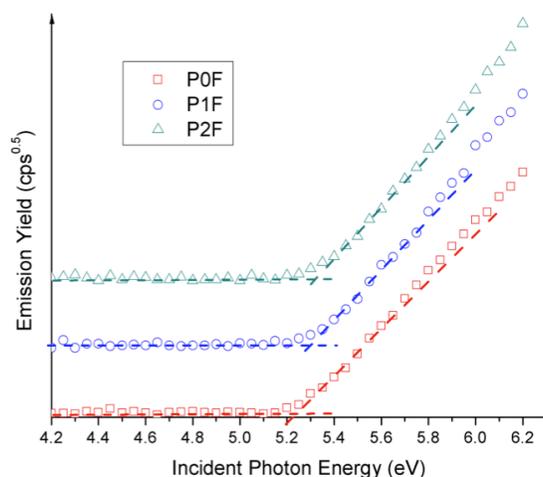


Figure S2 Photoelectron spectroscopy in air of **P0F**, **P1F** and **P2F** films (the dash lines were added to help visualize the curve onsets, $\text{HOMO}_{\text{P0F}} = -5.23$ eV, $\text{HOMO}_{\text{P1F}} = -5.30$ eV and $\text{HOMO}_{\text{P2F}} = -5.31$ eV).

Dark Current Density and Modified Shockley Equation Fitting

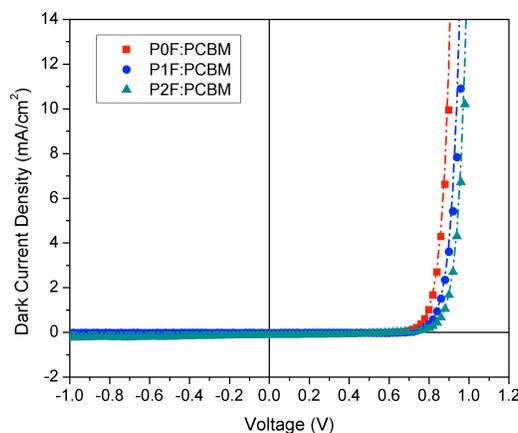


Figure S3 J - V characteristics of ITO/PEDOT:PSS/polymer:PC₆₁BM/Ca/Al under dark (Scatter) and simulation (Dot dash line) fitted according to the modified Shockley equation.

The ideality factor (n) and reverse saturation current density (J_0) were obtained by fitting the J - V characteristics of each device under dark with the modified Shockley equation:^{1,2}

$$J_{\text{dark}}(V) = J_0 \left\{ \exp \left[\frac{e(V - J_{\text{dark}}(V)r_s)}{nk_B T} \right] - 1 \right\} \quad (1)$$

where J_{dark} is the dark current density, J_0 is the reverse-bias saturation current density, e the elemental electron charge, $r_s = R_s \cdot \text{area of device}$ the specific series resistance, n the ideality

factor, k_B is the Boltzmann's constant and T the temperature. Furthermore, with n and J_0 obtained from fitting, V_{oc} of each device can be determined by:^{2,3}

$$V_{oc} = \frac{nk_B T}{e} \ln \left[\frac{-J_{ph}(V_{oc})}{J_0} + 1 \right] \approx \frac{nk_B T}{e} \ln \left(\frac{J_{sc}}{J_c} + 1 \right) \quad (2)$$

Table S1 below summarizes the fitting results of important parameters.

Table S1 Parameters of device obtained by fitting J - V characteristics under dark with modified Shockley equation

	J_0 (mA/cm ²)	n	J_{sc} (mA/cm ²)	R_{sh} (kΩ)	V_{oc} (V)	
					Simulated	measured
P0F:PCBM	3.74×10^{-13}	1.54	6.37	20±4	0.835	0.832
P1F:PCBM	2.30×10^{-13}	1.58	6.52	19±3	0.878	0.872
P2F:PCBM	4.03×10^{-14}	1.51	6.84	22±3	0.912	0.914

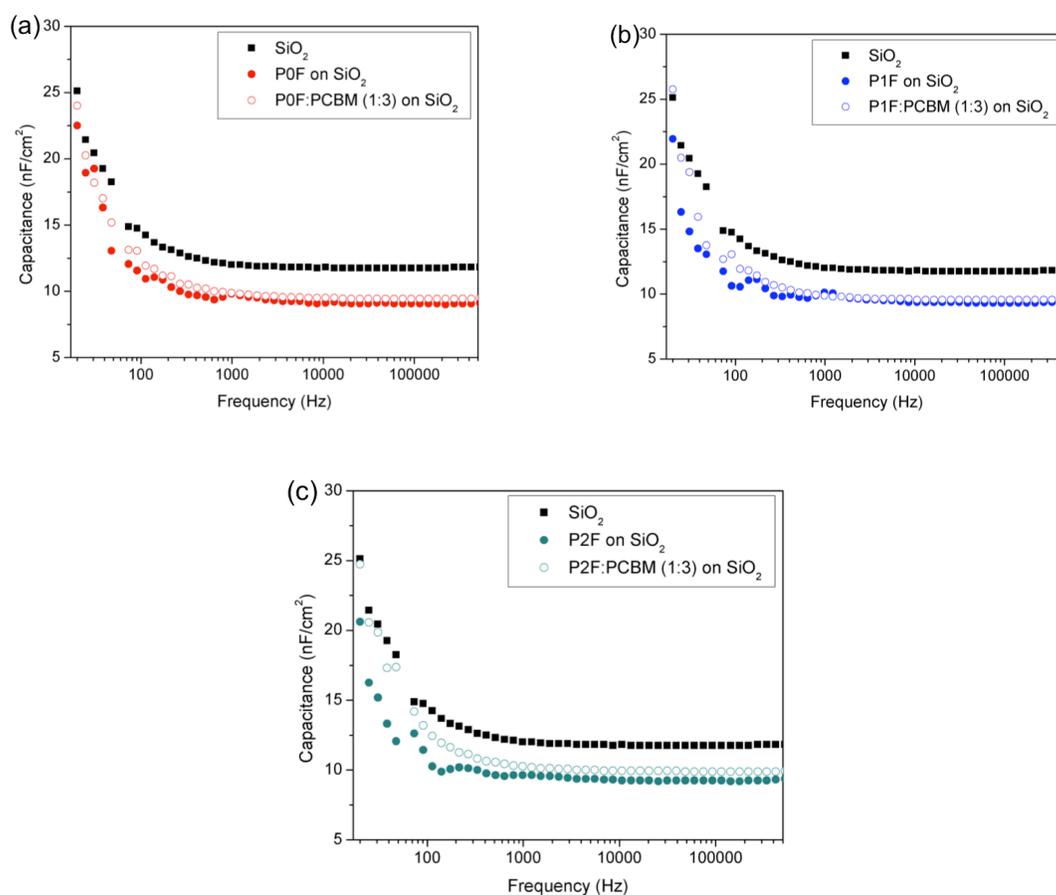


Figure S4 Capacitance measurement of (a) **P0F**, (b) **P1F** and (c) **P2F** pure and blends film on 300 nm SiO₂ layer.

Reference:

1. S. M. Sze and Ng, *Physics of semiconductor devices*, Wiley-Interscience, Hoboken, N.J., 2007.
2. J. Xue, S. Uchida, B. P. Rand, and S. R. Forrest, *Appl. Phys. Lett.*, 2004, **84**, 3013.
3. X. Tong, B. E. Lassiter, and S. R. Forrest, *Org. Electron.*, 2010, **11**, 705.